
Development of Next Generation Display Technologies – Quantum Dot LEDs

Material Synthesis and Processing, Device Design and Application

Armin Wedel, Yohan Kim, André Geßner, Benjamin Heyne, Hyung Seok Choi, Silvia Janietz
Fraunhofer Institute for Applied Polymer Research, Geiselbergstr. 69, Potsdam, Germany



Outline

- **Introduction to Fraunhofer Society and the Fraunhofer IAP**
- Contributions to OLED development
- QD design, synthesis and applications
- QD-LED devices
- Active matrix OLED (AMOLED)
- Summary

Fraunhofer IAP

- First Polymer OLED (1994)
- Organic Electronic (1999)
- Passive Matrix OLEDs (2001)
- OLED Printing (2006)
- **Indium Phosphid Quantum Dots (2009)**
- Pilot Line (2012)

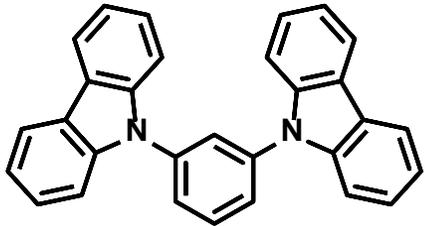


Outline

- Introduction
- **Multilayer OLED solvent processing with polymers**
- QD design, synthesis and application
- QD-LED devices
- Active matrix OLED (AMOLED)
- Summary

Charge Transport Materials in OLED Applications

Small molecules (SM)



- Low T_g
- When applied from solution
 - Recrystallization problems
 - De-wetting

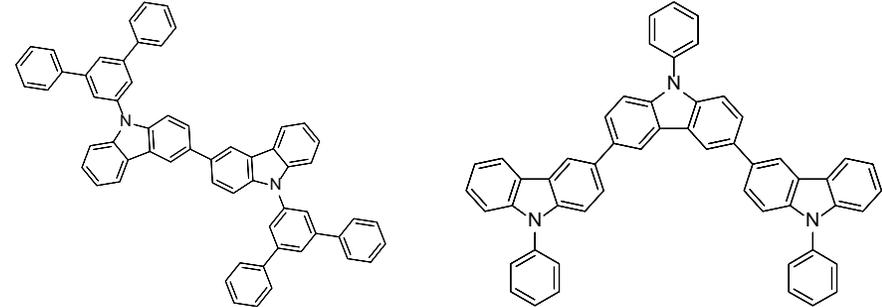
Increase of molecular weight

[1]

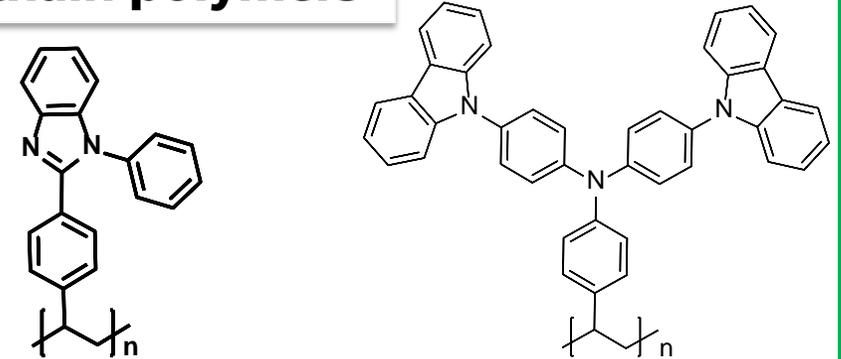
[2]

Fraunhofer IAP

Dimerization / Extension



Side-chain polymers

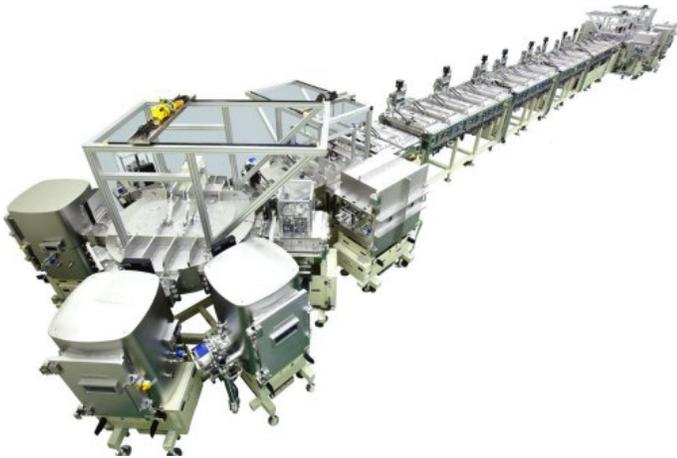


Similar optoelectronic properties as SM

OLED Multilayer Processing

Evaporation in Vakuum

- Good performance and lifetime
- Reproducible multi-layer processing
- High invest
- Low materials exploitation



Sunic System has developed the large size inline system from Gen 1 to Gen 5.5 and using Sunic system's linear evaporation source, can supply over Gen 8 substrate.

Solvent Processing and Printing

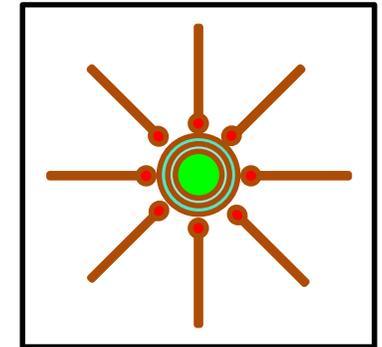
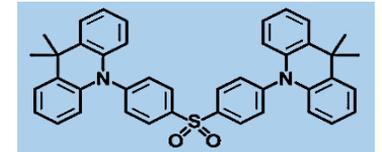
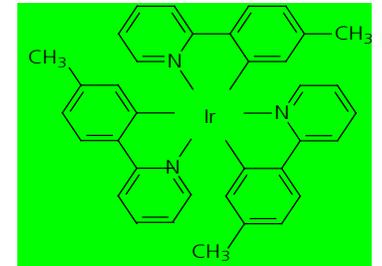
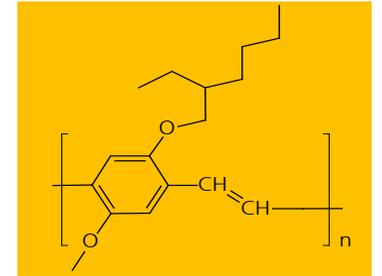
- Moderate performance and lifetime
- Multi-layer processing by crosslinking
- Lower invest
- High materials exploitation



Tokyo Electron (TEL) announced a new OLED R&D inkjet printing system, the Elius 500 Pro that is capable of printing on 2-Gen substrates (370x470 mm).

From OLEDs to the next generation: QD-LEDs

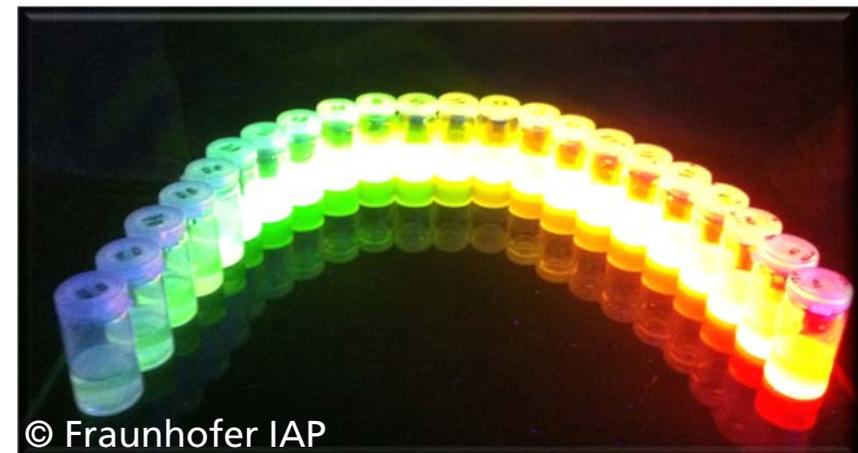
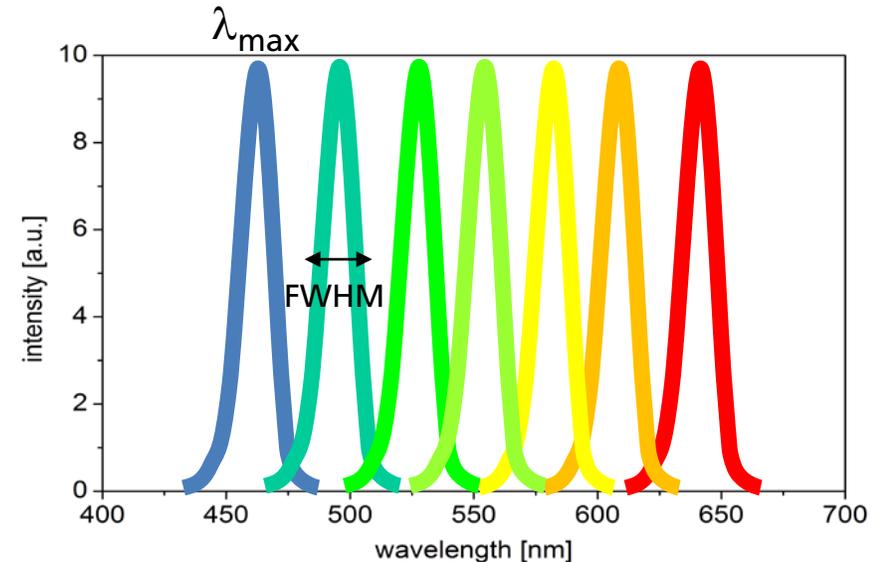
- **Singlet-emitters (PLED)**
 - Conjugated polymers MEH-PPV, low efficiency
- **Triplet-emitters (PhOLED)**
 - Ir(ppy)₃ as component, high efficiency, evaporate or soluble based
- **TADF Emitter**
 - Thermally activated delayed fluorescence
- **Quantum Dots (QDEF, QD-LED)**
 - Semiconductor nanoparticle with inorganic core/shell and organic ligand, tunable color and narrow FWHM



Quantum Dots – special semiconductor nanoparticles

Optical properties are depending on the following parameters:

- **Absorption- and emission properties** (I_{\max} [nm]) are depending on the particle size
- **The full width at half maximum** (FWHM [nm]) is depending on the particle size distribution
- The **Luminescence and Quantum Efficiency** (QY [%]) is depending on the surface defects of the nanocrystal



© Fraunhofer IAP

CdSe-QDs

Quantum Dot Stream in Display

PL

EL

QDEF (QD Enhanced Film)

- blue LED + red QDs + green QDs
- Samsung 8K UHD QLED TVs

QDCF (QD Color Filter)

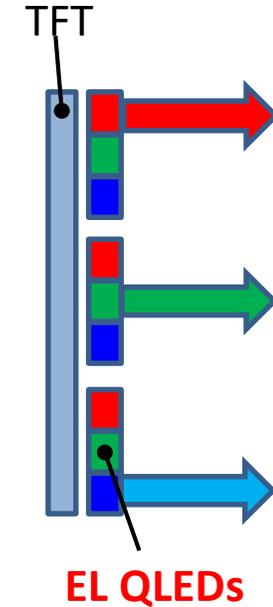
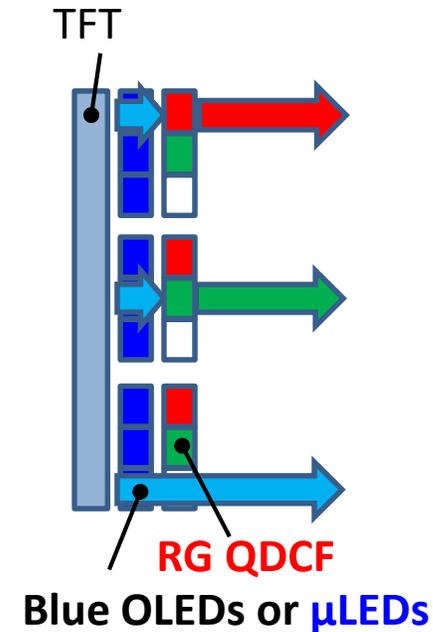
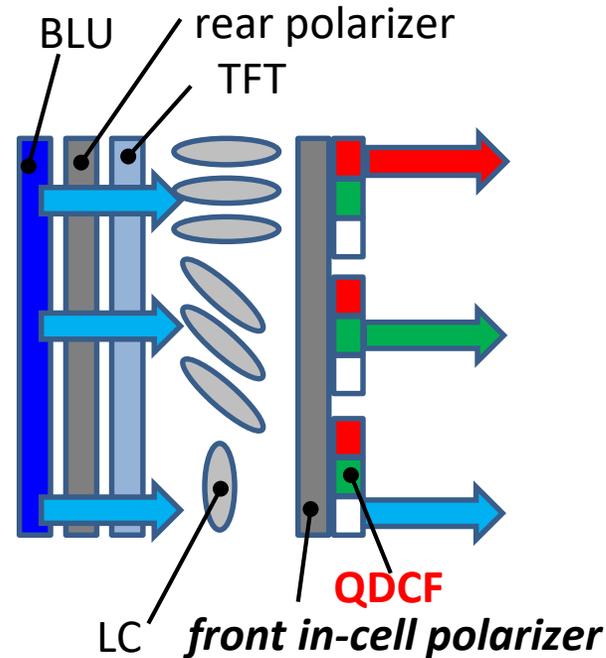
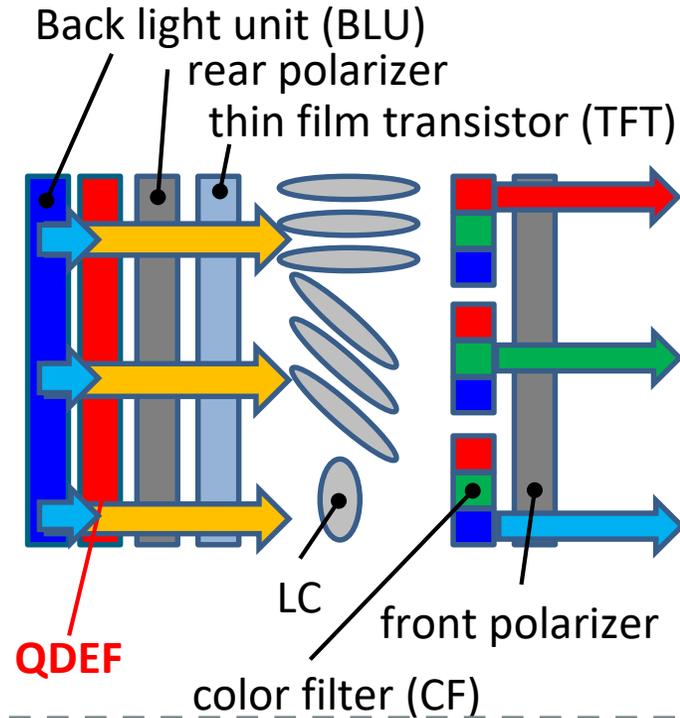
- 50% higher efficiencies
- widest viewing angles
- In-cell polarizer / high absorption

QDCF + Blue OLED

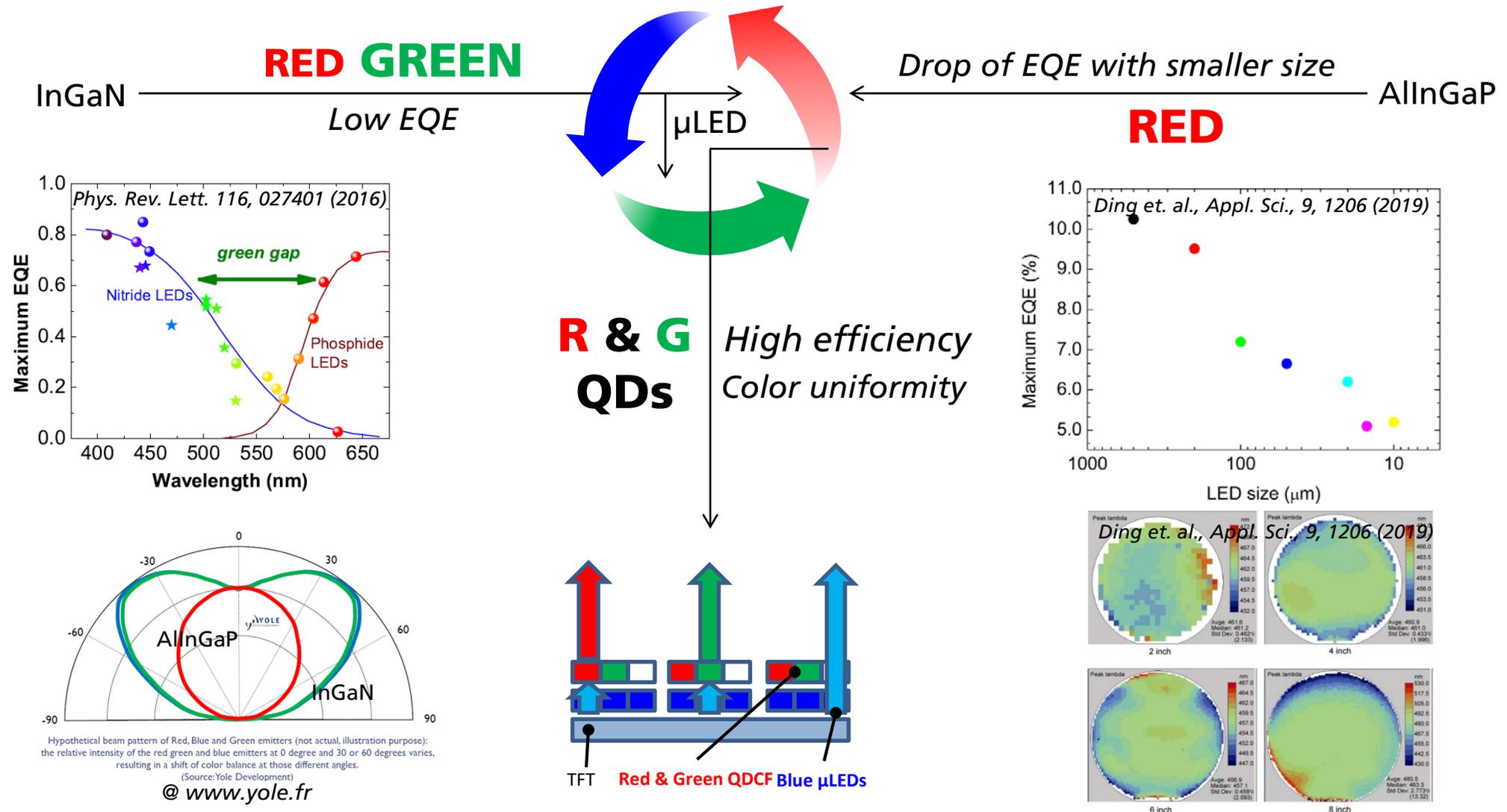
- No BLU, polarizer & LC
- Low color distortion
- Thin & Flexible

EL-QLEDs

- Self-emitting
- Wide color volume
- Conformable display
- Low cost



μLEDs with Quantum Dots - beyond the pick & place



Challenges for EL-QLEDs

- High performance with Cd-based QDs



- *EQE ~23% (63~100 cd/A)
- *T50: 7k ~ 1700k hour at 100 cd/m²
* *Nature photonics* 13, 2019, 192-197

- Cadmium-free QDs

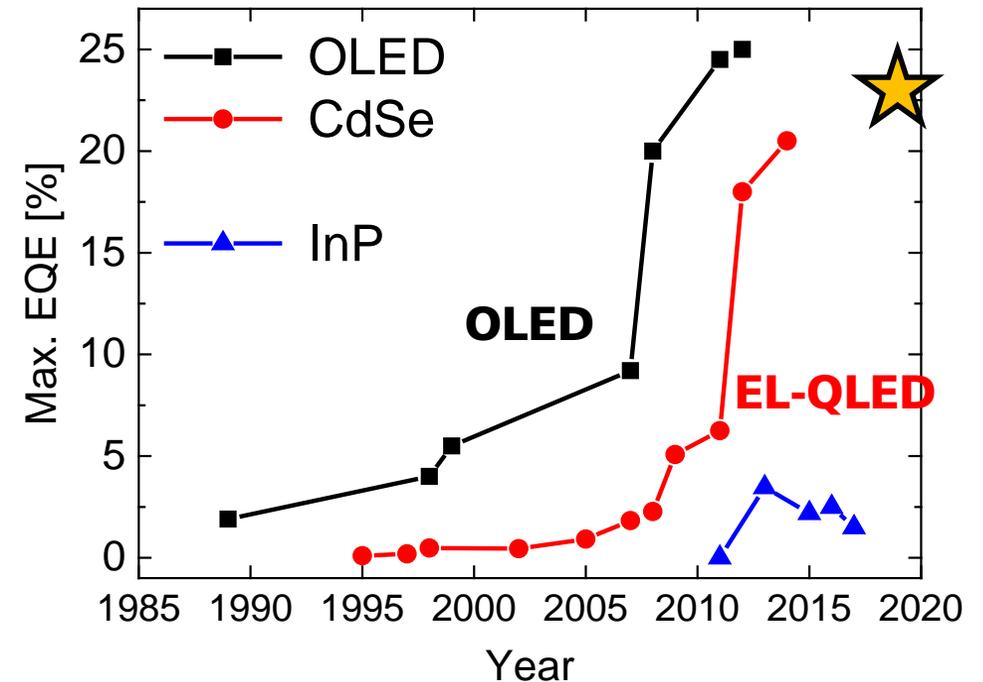


RoHS

- InP, ZnSe, CuInS₂, Perovskite...
- relatively low performance and stability

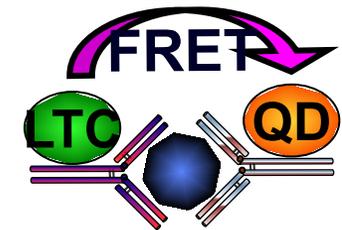
- Efficiency roll-off, low brightness, life time → sophisticated system design for carrier balance, low luminance quenching and recombination zone (RZ)

- Color saturation for BT. 2020



QDs @ Fraunhofer IAP - Technology and Application

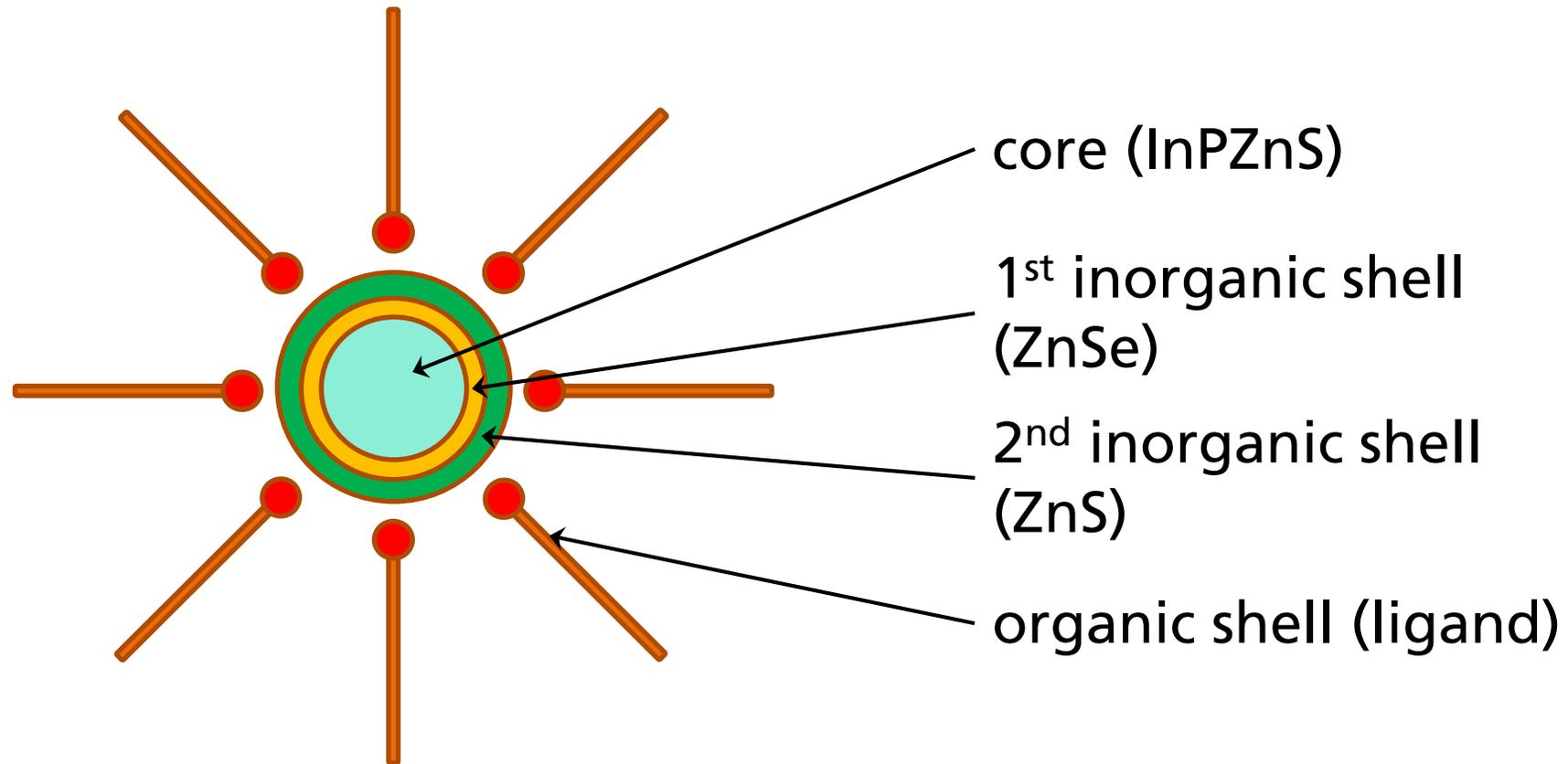
- **QD based OLED**
 - OLED set-up and 4th generation of emitting materials
- **QD as converting material for lighting application**
 - QD based enhancement films (QDEF) for display application in LED backlights
- **QD as special material for security application**
 - QDs printed on paper or plastics
- **QD as highly sensitive sensor materials** for bioanalytical applications



Outline

- Introduction
- Multilayer OLED solvent processing with polymers
- **QDs: synthesis approaches and design principles**
- QD-LED devices
- Active matrix OLED (AMOLED)
- Summary

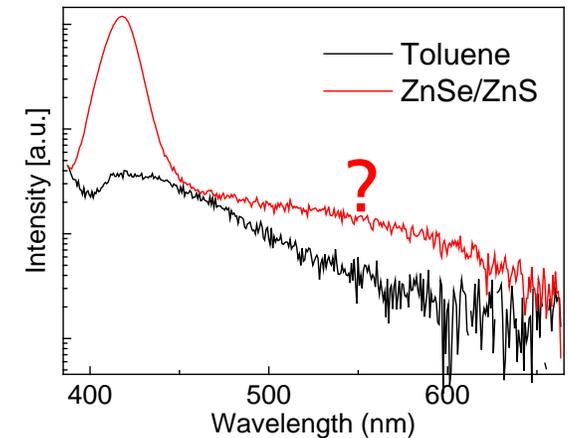
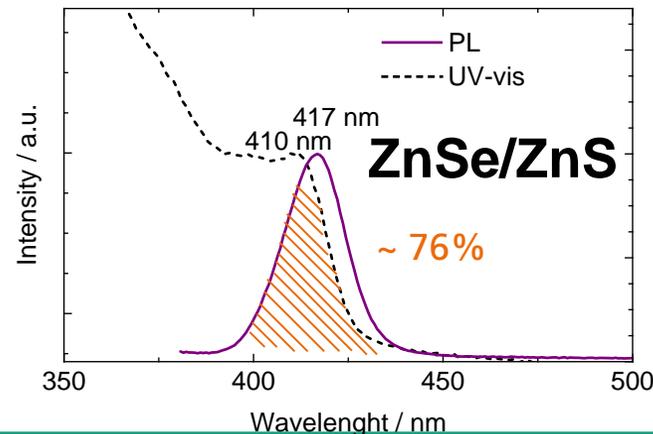
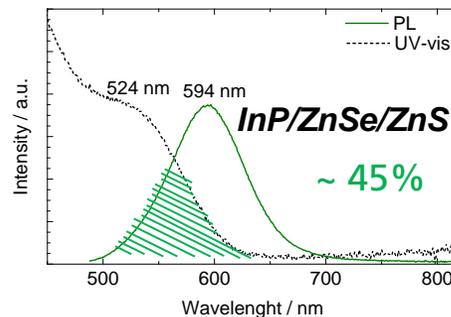
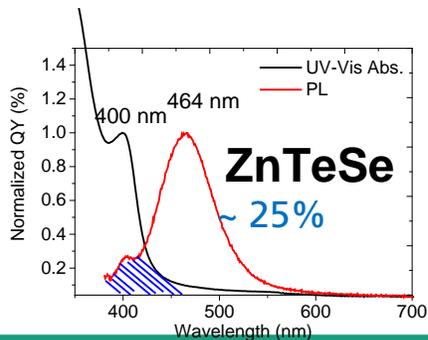
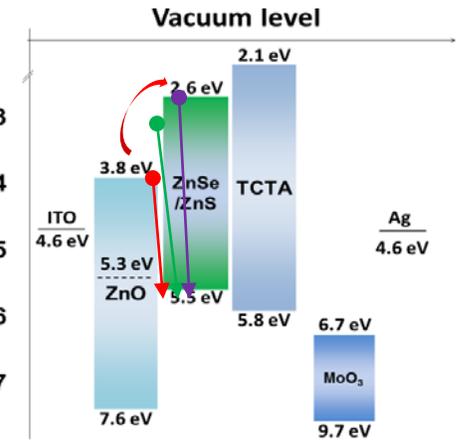
Quantum Dot System Structure



ZnSe/ZnS QDs for blue QDs – current issues

Q. what is the main reason of low efficiency and parasitic emissions?

- A. Inverted: not efficient electron injection by energy barriers ~ 1.2 eV
→ Other ETLs for low injection barriers... PEIE, ZnMgO
- B. The defects (shown in PL) of QD disturb the charge injection?
→ Further passivation of QDs ~ thicker ZnS, alloyed ZnSeS/ZnS shell
- C. Stronger overlap between PL & UV-Vis Absorption ~ 76% (45% w/ InP)
→ Stronger self-quenching?
→ Te doping..



Status QD synthesis @ Fraunhofer IAP | Focus on InP and ZnSe

■ CdSe

- Best performance for green and red

■ Cd free QDs (green and red)^[1]

- QY comparable for green and red
- FWHM to be improved

■ Cd free blue QDs^[2]

- ZnSe for blue in development
- QY about 30%, FWHM < 30 nm

■ General approaches

- Color tuning via reaction conditions
- Ligand tuning to adjust solubility

CdSe	green	red
QY (%)*	> 81	> 85
FWHM (nm)*	< 26	< 34

InP	green	red
QY (%)*	> 85	> 77
FWHM (nm)*	< 42	< 58

ZnSe	blue
QY (%)*	~ 30%
FWHM (nm)*	< 20

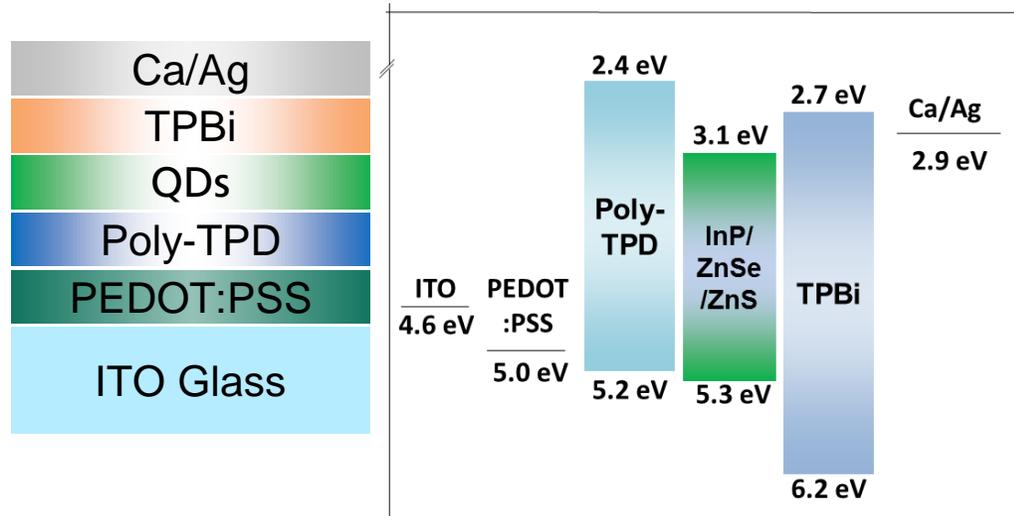
*all data measured in solution

Outline

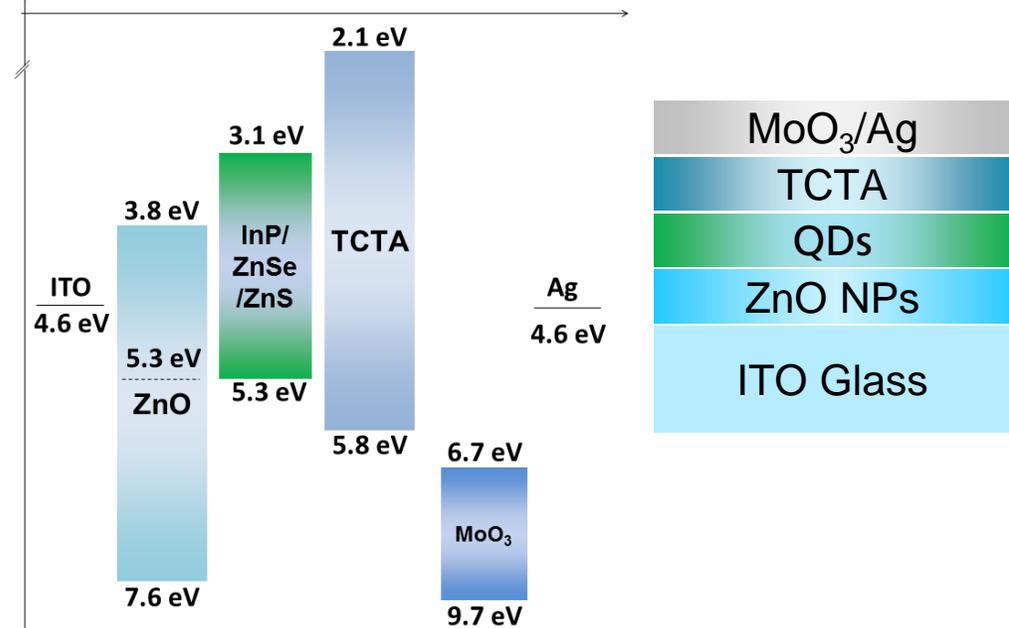
- Introduction
- Multilayer OLED solvent processing with polymers
- QD design, synthesis and application
- **Complex material setups in QD-LED devices and the optimization challenge (ETL, QDL, ETL vs QDL, QDL vs HTL)**
- Active matrix OLED (AMOLED)
- Summary

Device architectures of QD-LEDs

conventional

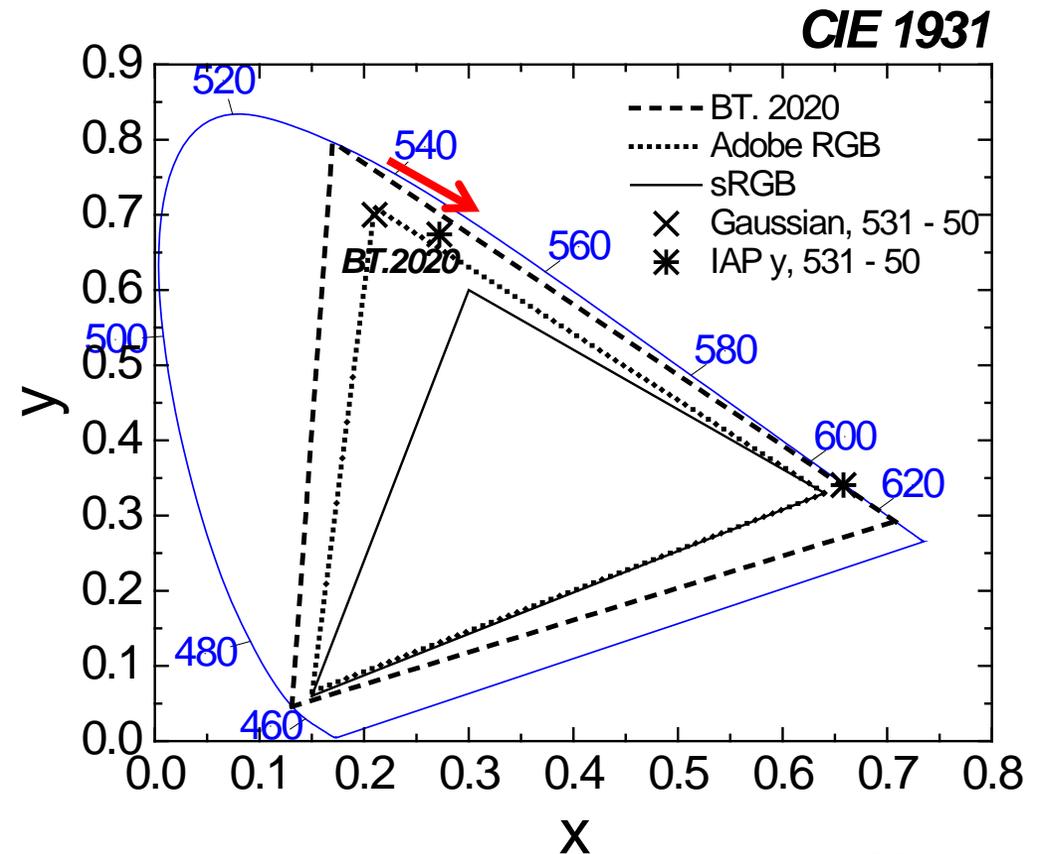
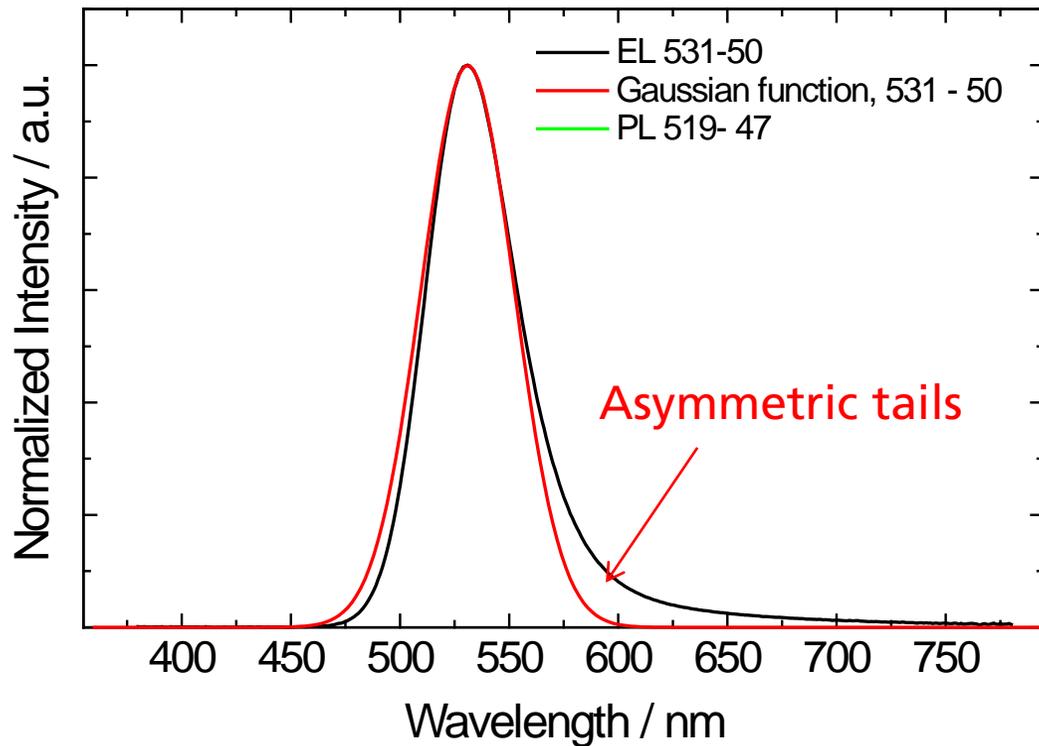


inverted



- Multi-layer device structure, orthogonal solvent process
- Uniform film, efficient charge carrier balance (injection, transport, block)
- ZnO NPs: Auger assisted electron injection, charge neutralization effect

CIE1931: Green with Gaussian vs. QD spectrum

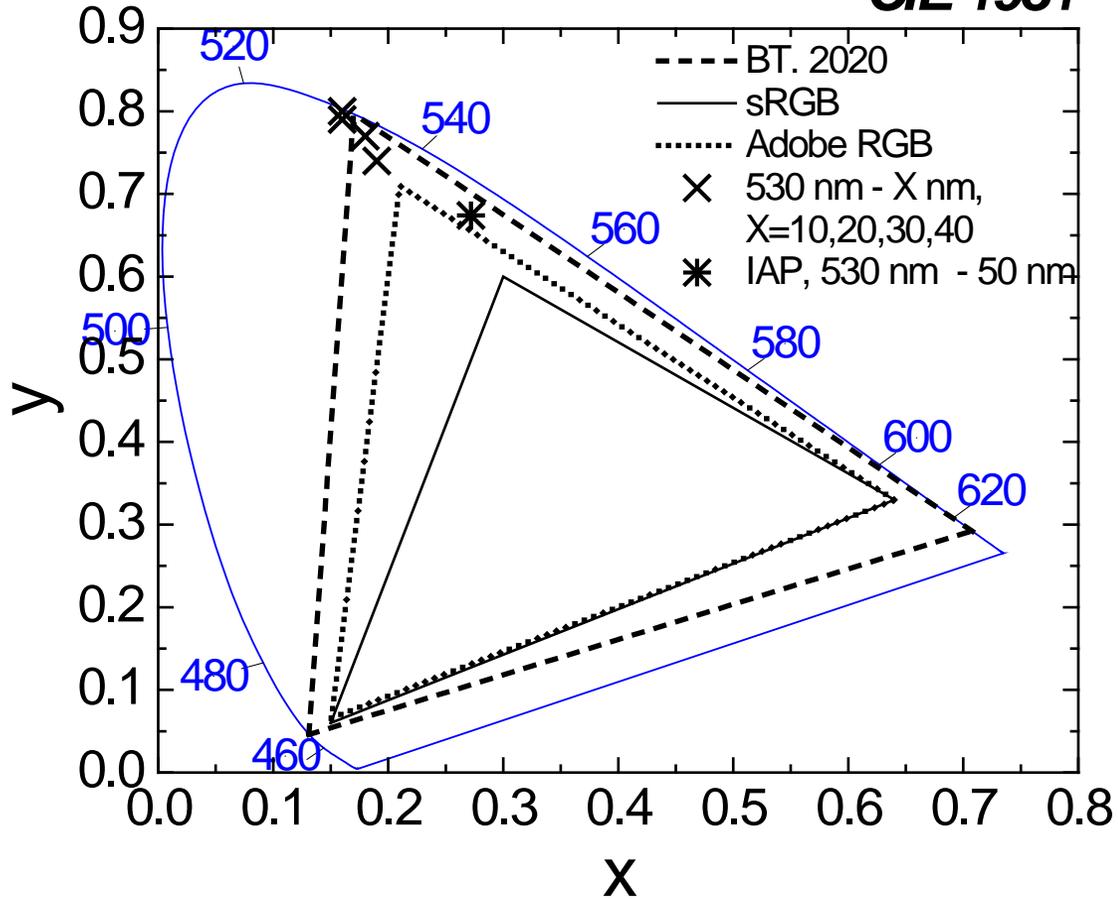


- Even though the same λ_{peak} and FWHM, color coordinate is very different
- Asymmetric tails from QDs \rightarrow Green is sensitive to color purity

CIE1931 vs CIE1976 (Gaussian spectrum and IAP QDs)

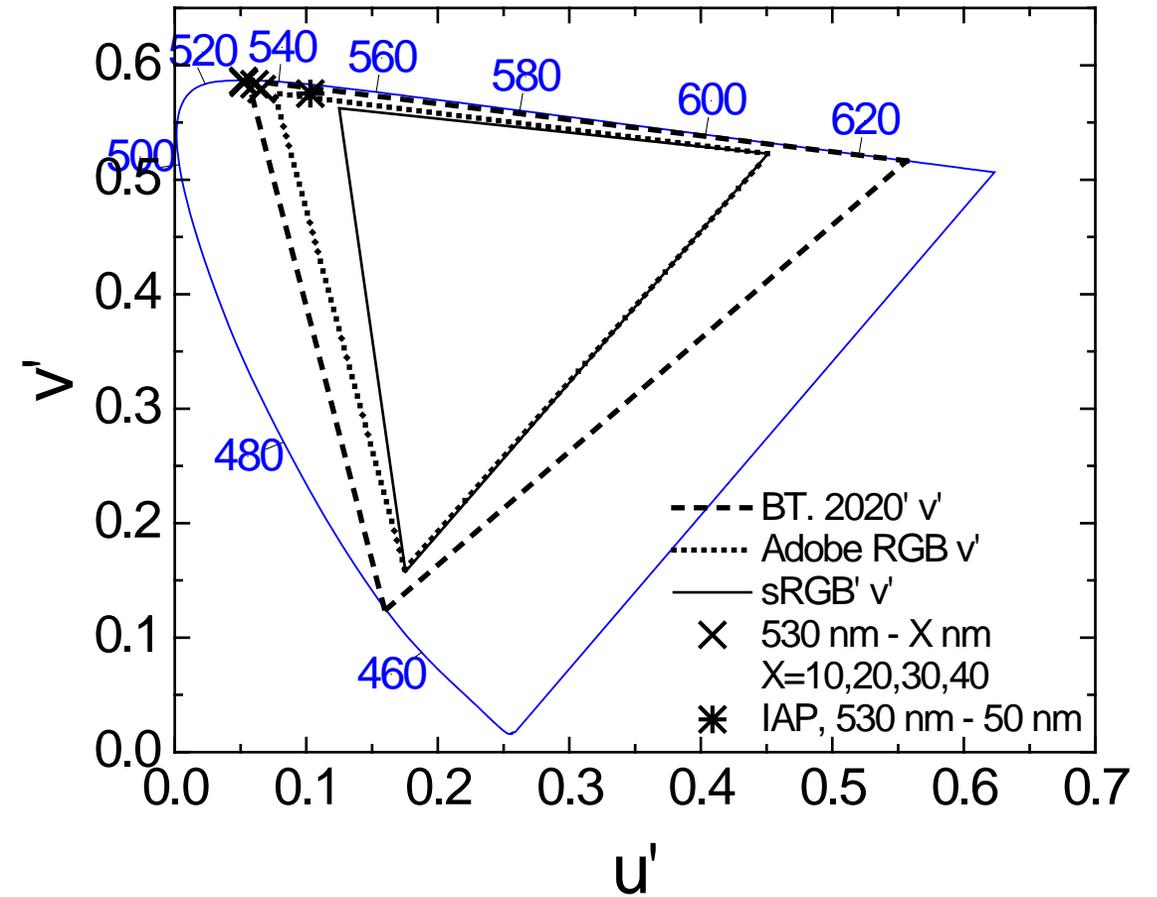
For measurement

CIE 1931

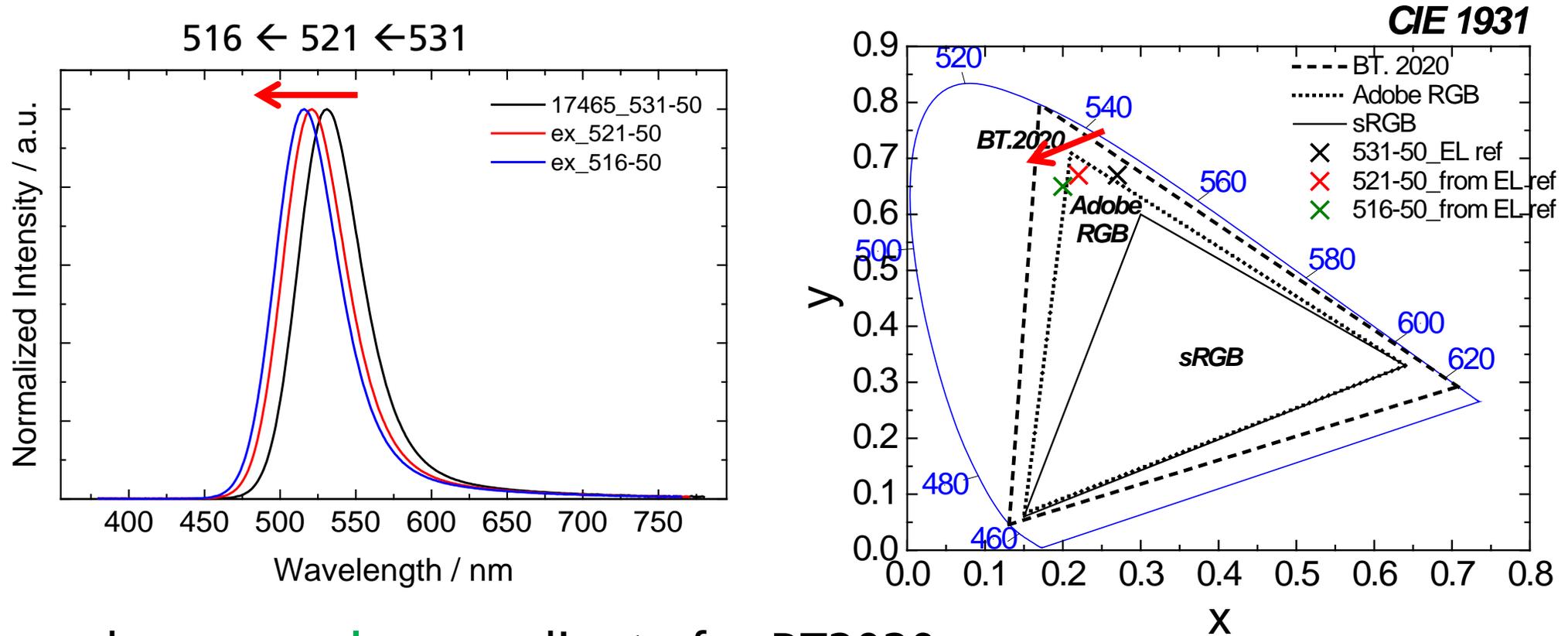


For human eye

CIE 1976



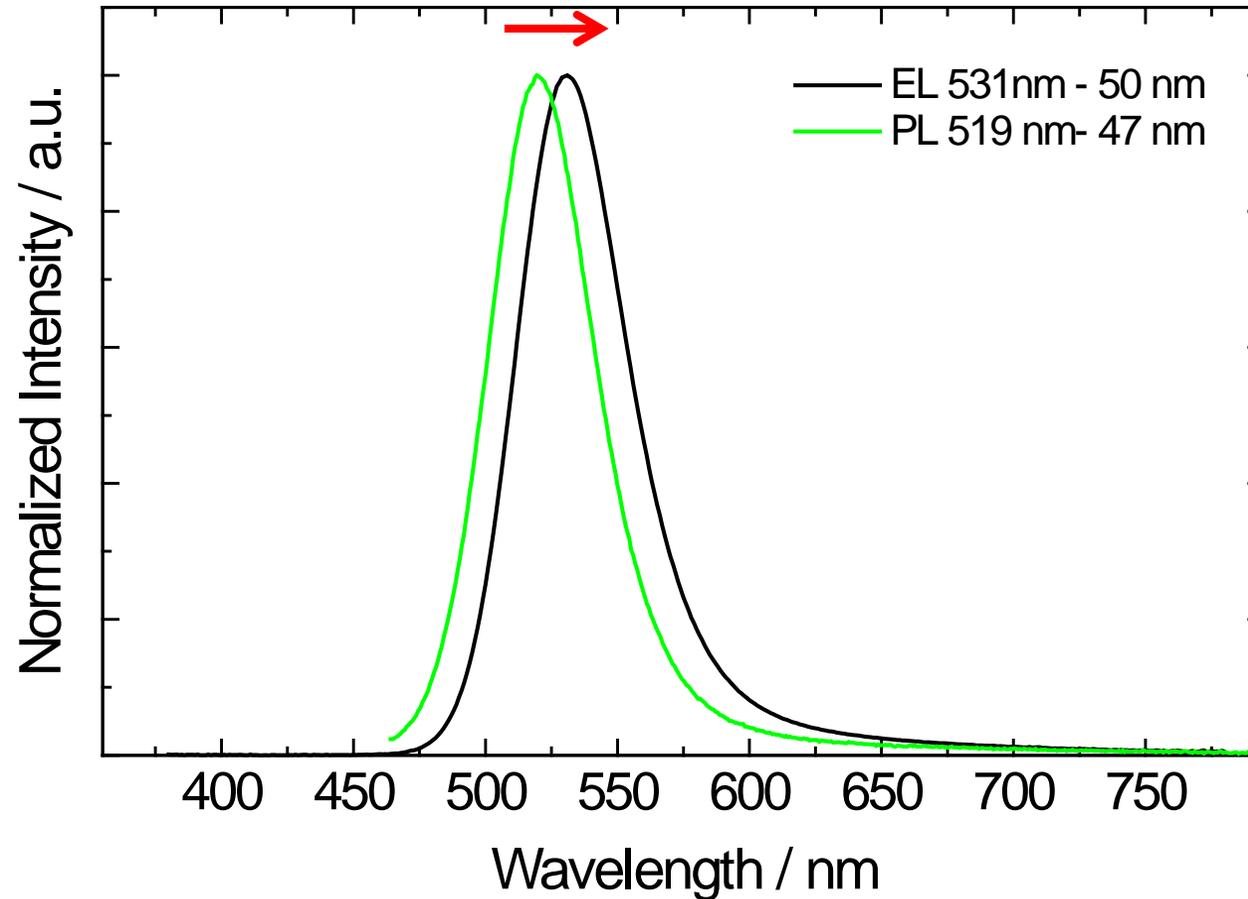
Peak wavelength shift with reference EL spectrum



To reach **green color** coordinate for BT2020

→ FWHM should be narrow down to ~ 30 nm

Red-shift from PL to EL $\lambda_{\text{peak}} > 10$ nm

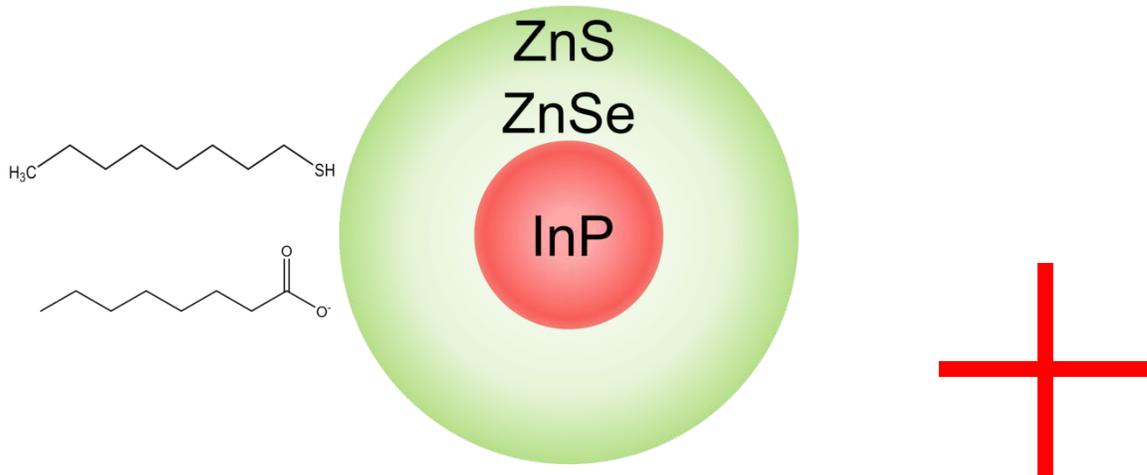


For the design QD, **red-shift** must be concerned.

QD spectrum target for BT2020

Color	BT2020, monochromatic (nm)	CIE 1931 coordinate (x,y)	98.4% of BT2020 DOI:10.1364/OE.23.023680		95% of BT2020 DOI:10.1364/OE.23.023680	
			λ_{peak} (nm)	FWHM (nm)	λ_{peak} (nm)	FWHM (nm)
Red	630	0.708, 0.292	634.3	20	634.3	30
Green	532	0.170, 0.797	530.6	20	530.6	30
Blue	467	0.131, 0.046	465.8	20	465.8	30

Conventional QD-LEDs → Inkjet printing



Crosslinkable hole transport layer

- Thermal crosslinking
- Orthogonal solvent process
- Avoiding interfacial mixing
- Enhanced film stability

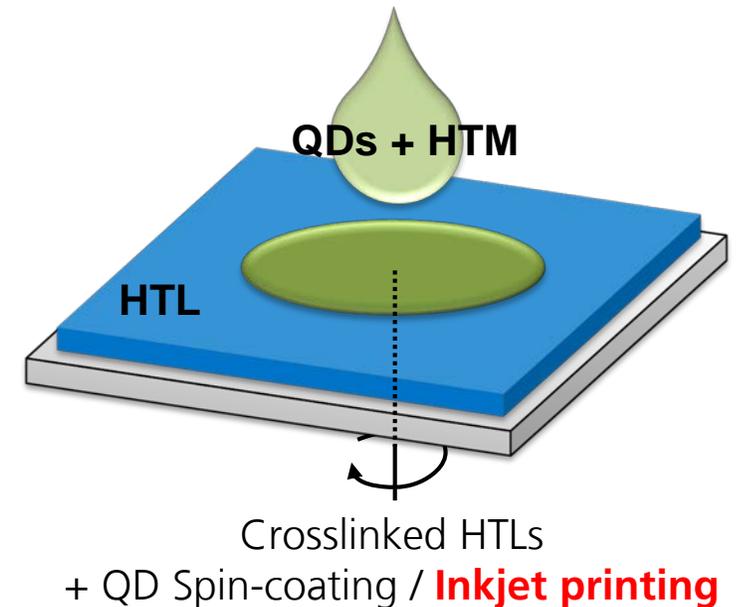
QD design for QD-LEDs

Structure: InP/ZnSe/ZnS

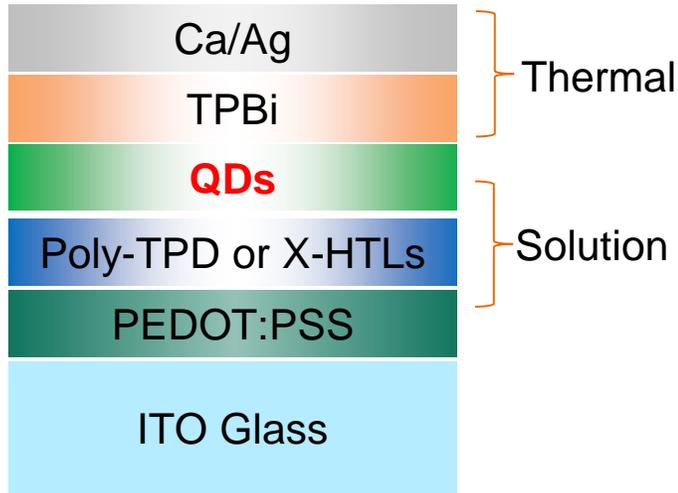
Multi-shell design

Ligand design

Quantum Yield (QY) & Purity

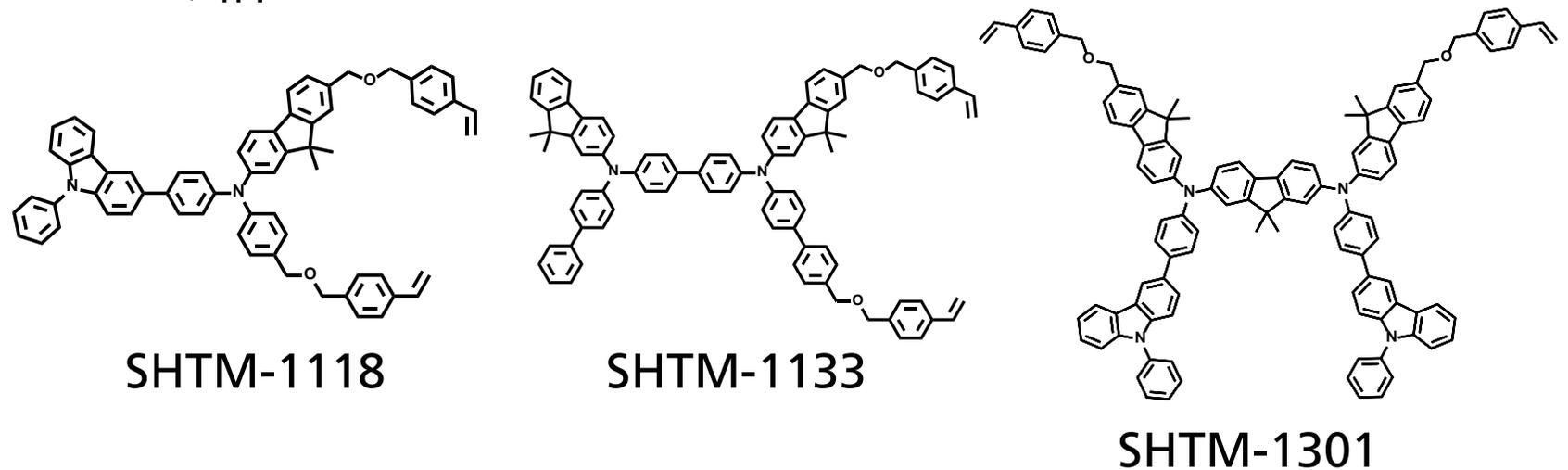
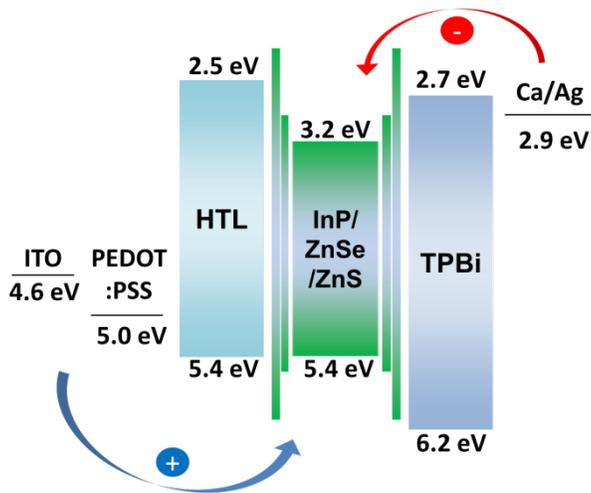


X-linked HTLs + different ligands and Zn precursor



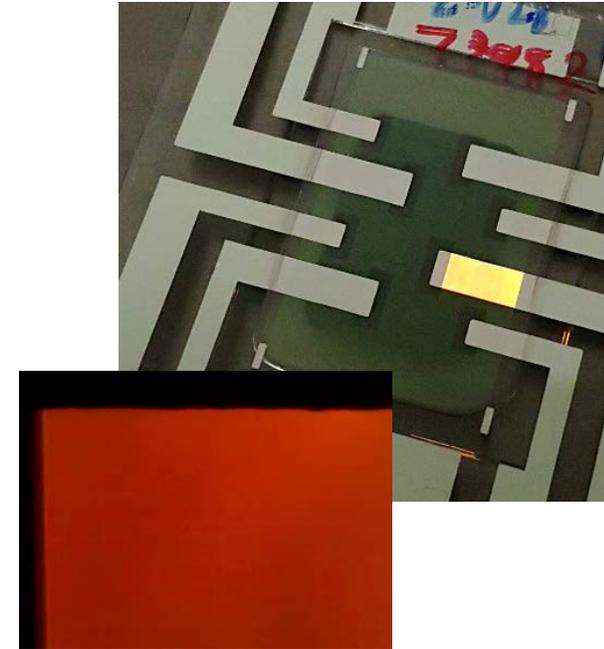
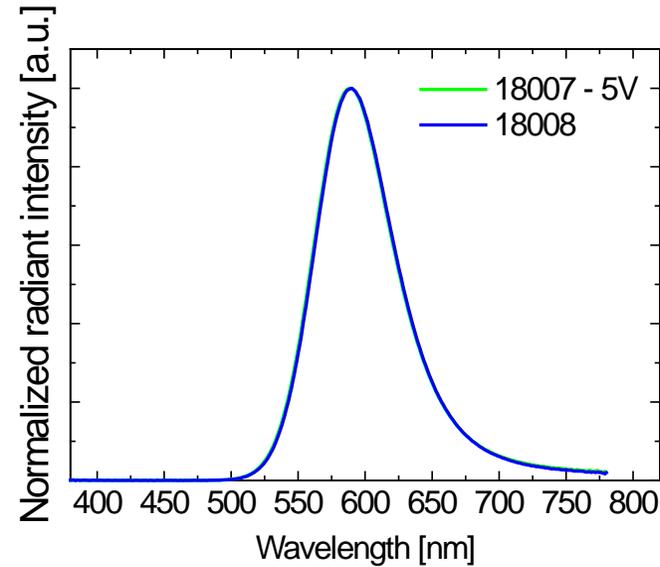
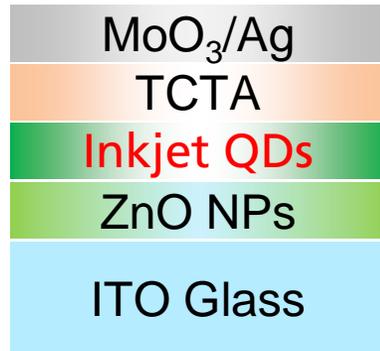
HTL layer	R_q / R_{pv} (nm)	HOMO (eV)	Max. CE (cd/A)	Luminance @ 7 V (cd/m ²)
Poly-TPD	1.70 / 51.59	5.18	10.1	890
SHTM-1118	0.60 / 8.45	5.48	11.5	800
SHTM-1133	0.60 / 7.80	5.54	13.7	1400
SHTM-1301	0.65 / 5.41	5.42	11.6	2200

μ_h : SHTM-1118 > SHTM-1133 > **SHTM-1301**



Inkjet printed (in air) inverted EL-QLEDs

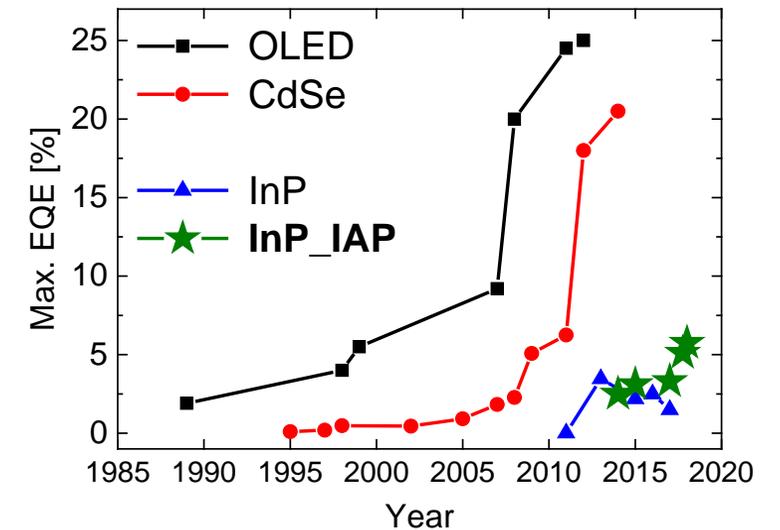
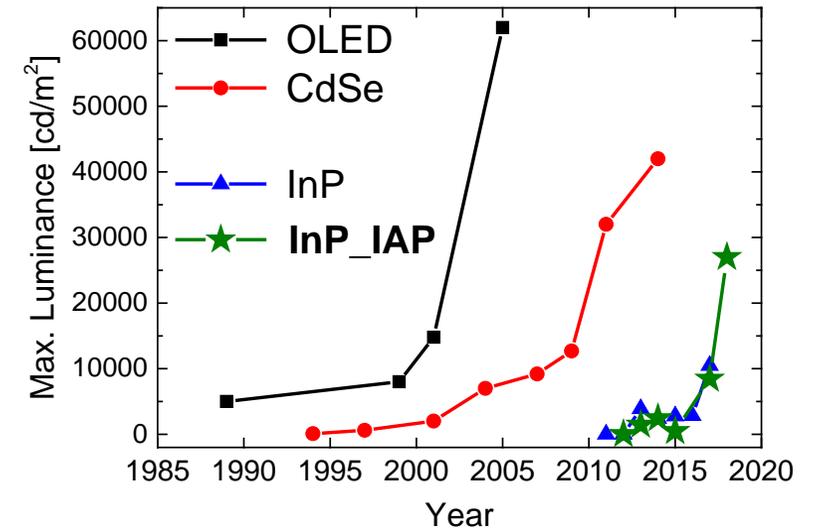
Device results



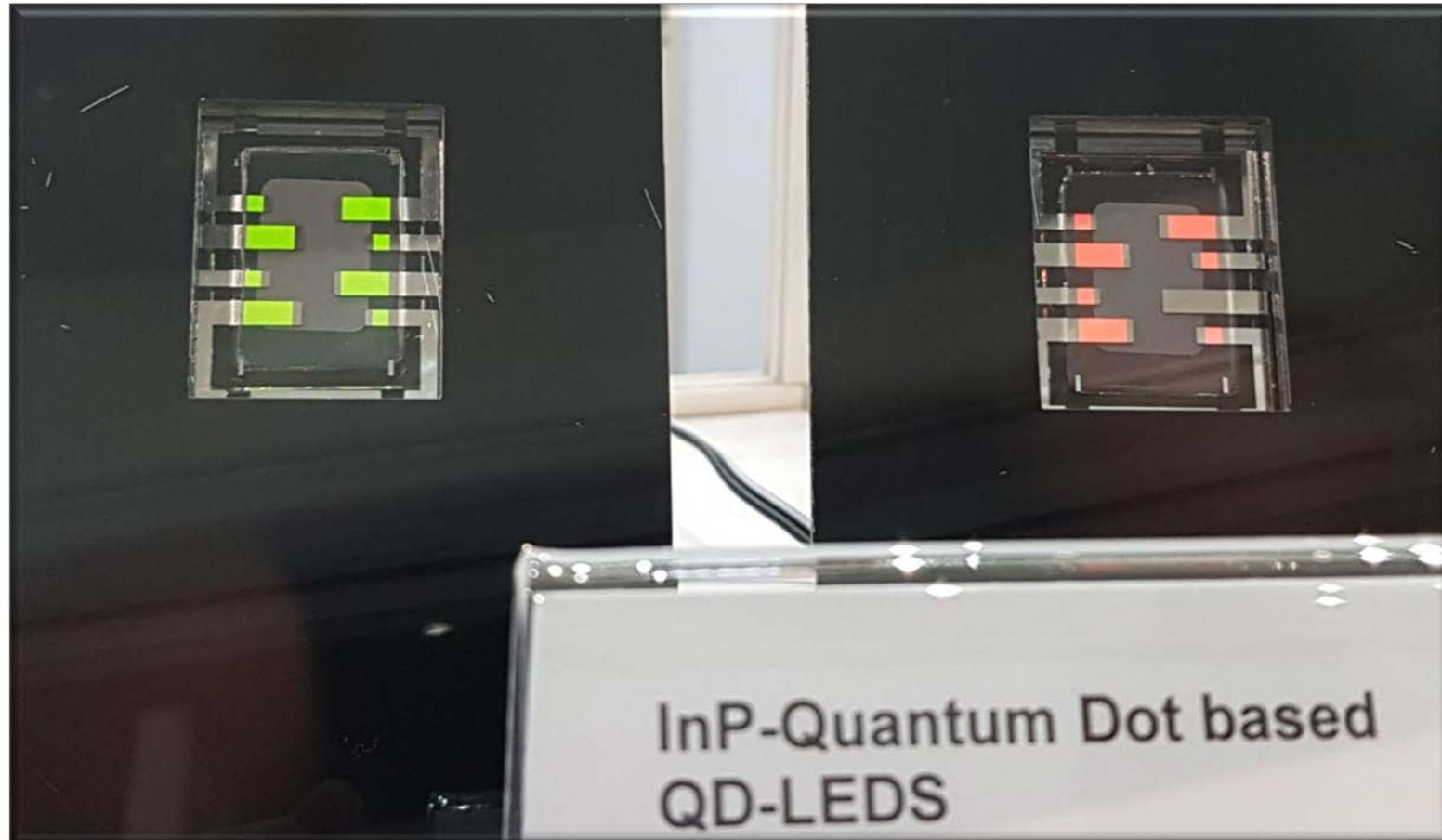
- QD layer with QD ink –600 dpi vs. 500 dpi
 - All device show pure EL spectrum
 - $V_{th} \sim 2$ V (similar to spin-coated one)
 - Max. efficiency and luminance: 1.400 cd/m²
 - Current efficiency is rather poor compared to the spin-coated devices in N₂.

Summary of InP-based QD-LEDs

- Remarkable increase of brightness of QD-LEDs
 - **20.000 ~ 28.000 cd/m²**
 - **3.3 ~ 5.7 % EQE**
- **Interaction between QDs and mid-gap states of ZnO NPs is the key!**
 - **QD layer thickness is important**
 - **Good performance requires smooth and stable ZnO NP layer**
- The feasibility of InP/ZnSe/ZnS QDs as the future source of Cd-free QD-LEDs



Devices running for days straight



Summary

- **InP/ZnSe/ZnS QD design** for improved performance
- QD **design and purity** trump QY
- Good performance requires **smooth and stable ZnO NP layer**
- **Thickness of QD layer** is very important for device performance
- **Complex device systems** require different optimizations depending on material combinations (reverse trends observed)
- Device performance: **20,000 ~ 27,260 cd/m²**, 10~11 cd/A, up to 5.7% EQE
- First steps towards **ESJET printable AMQD-LED** devices

ToDo's

- QD and QD-LED: efficiency, stability, design
- profound understanding of:
 - processes in a driven device (non-radiative losses, charge effects, etc.)
 - how to tune charge carrier balance effectively
 - how to design the recombination zone
 - how to reduce luminance quenching
 - degradation(?) of QDs
- **New device concepts (tandem structure) with regards to material choice (move away from OLED optimized materials) and maybe even stack design**
- **Full-color R.G.B. patterning process (Inkjet-printing, lithography....)**

Current project (ELQ-LED)

ELQ-LED: Exploring quantum materials - new ways to realize innovative optoelectronic components (2017 – 2020)

BMBF project ELQ-LED for basic research on quantum materials as light sources / 2018

[Researching New Highly Efficient OLEDs with Quantum Materials](#)

Press release of the BMBF joint project ELQ-LED / Merck KGaA / 1.2.2018



© Fraunhofer IAP

"Exploring quantum materials - new ways to realize innovative optoelectronic components (ELQ-LED)" is the title of a joint project funded by the German Federal Ministry of Education and Research (BMBF) with 5.5 million euros. The aim of the project is to develop quantum materials for innovative applications in the display and lighting industries. The total budget of the project amounts to 9.1 million euros.

[MORE INFO](#)

SPONSORED BY THE

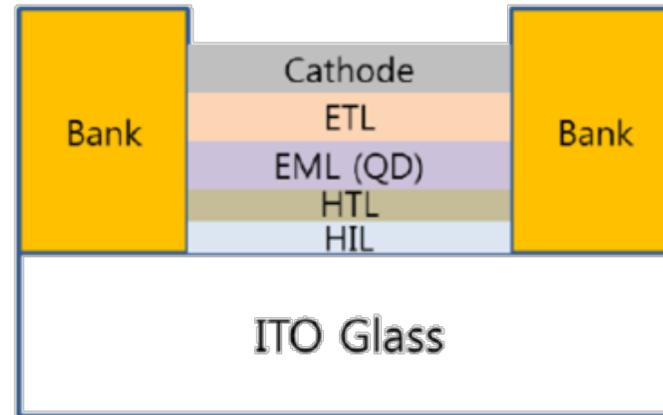
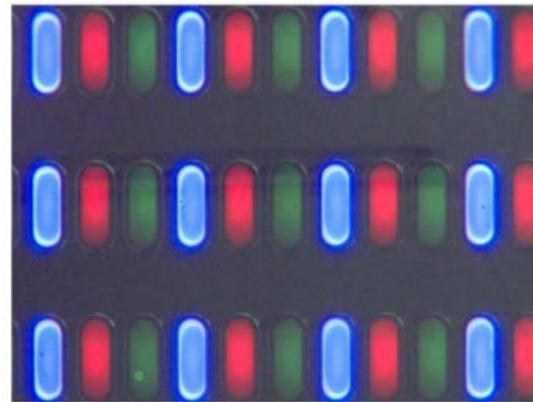


Federal Ministry
of Education
and Research

Current project (FiPaQ)

FiPaQ: **F**ine-**P**atterned eco-friendly **Q**uantum dot light emitting diode (2019 - 2022)

Development of materials and process technology for fine-patterned eco-friendly quantum dot light emitting diode



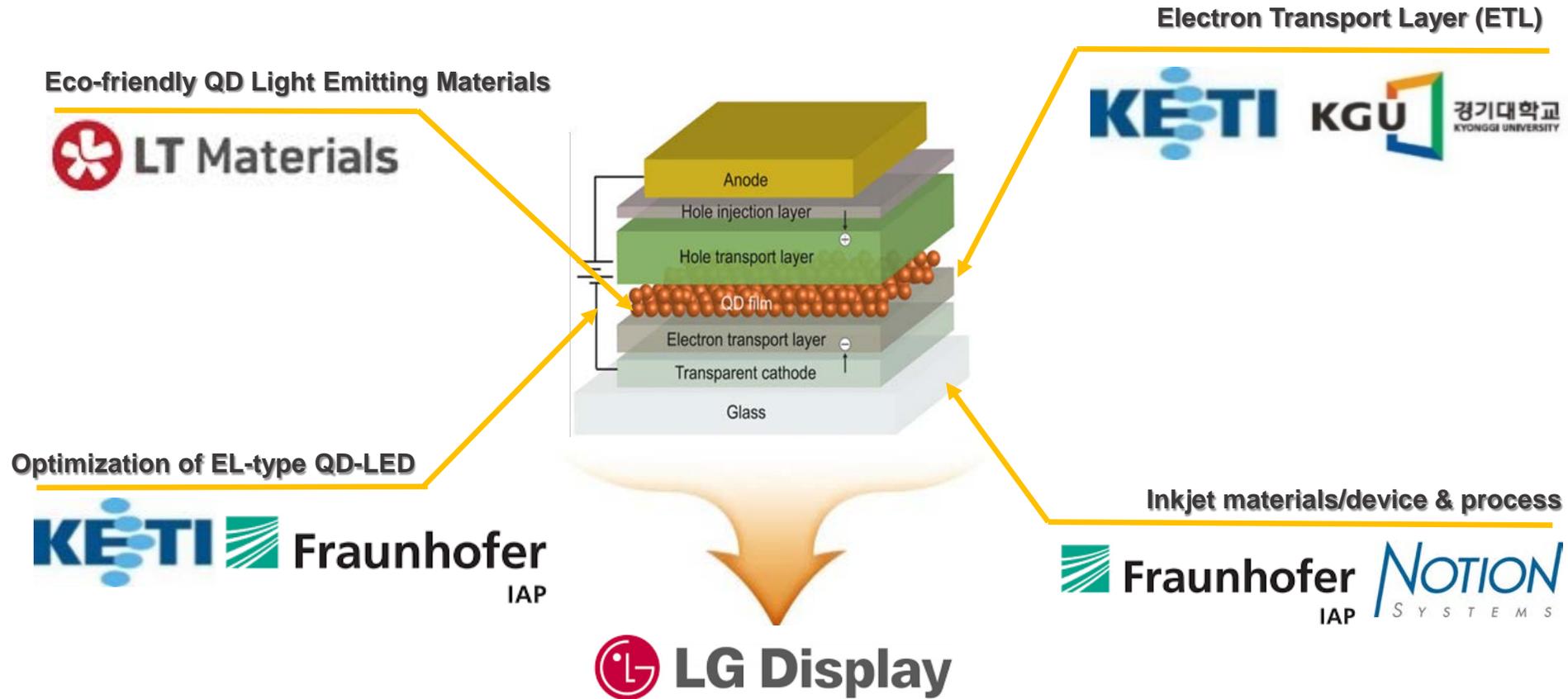
R.G. display
88 inch 8K-
Resolution
~ 100 ppi

German-Korean
joint R&D project



Ministry of Trade,
Industry and Energy

FiPaQ



Current project (CoCoMe)

CoCoMe: **C**olor **C**onverting **M**icro-**L**EDs (2019 - 2023)

Ultra high luminance(> 50knit) Micro Displays with 2,000 ppi, for AR application

New research project between Fraunhofer IAP and Korea Electronics Technology Institute (KETI) / 2019

[QD color filters for microLEDs](#)

Press release / Text: Julia Consten / 6.9.2019



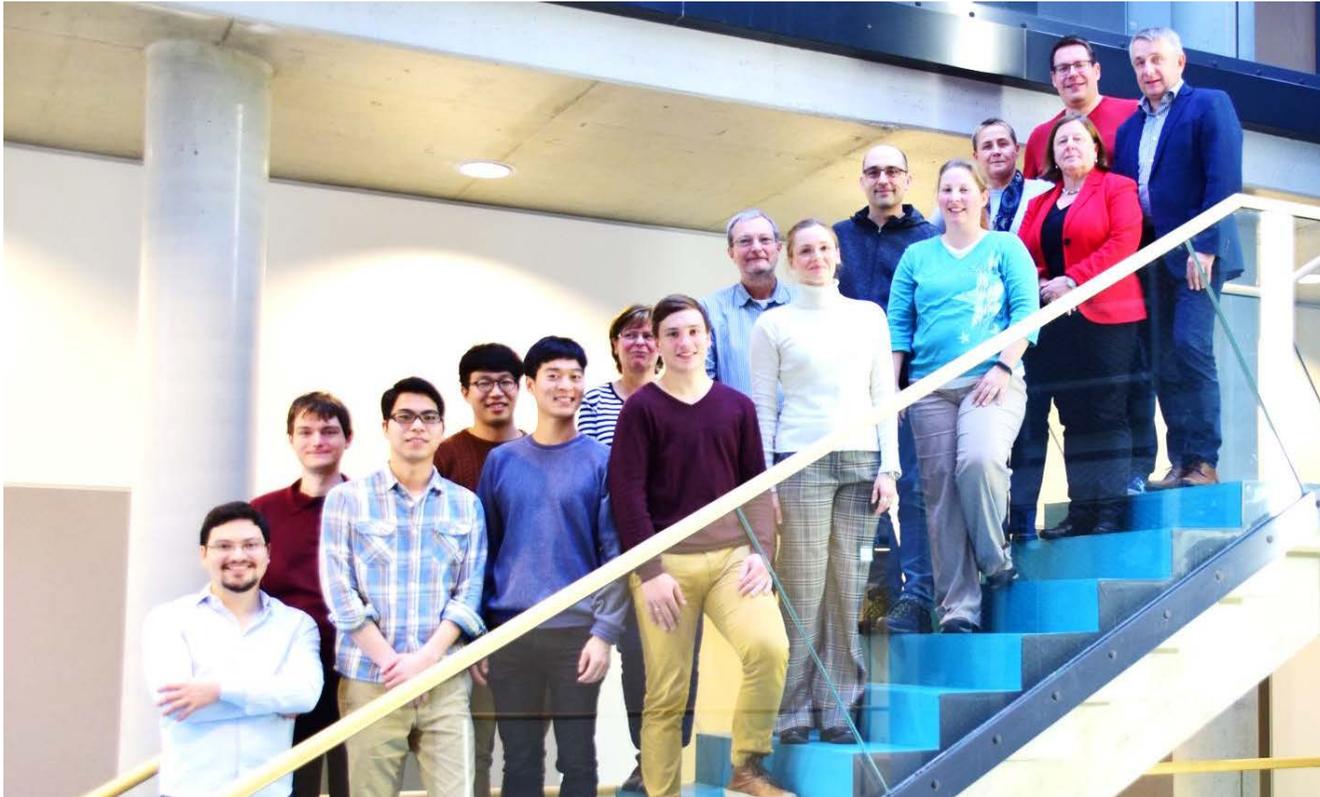
Quantum dot-based color filters for micro-LEDs are one of the most promising future technologies for displays. This technology makes displays even more brilliant, more efficient and even thinner, compared to displays with conventional color filters. The Fraunhofer Institute for Applied Polymer Research IAP and KETI have started working together on the development of printed QD color filters microLEDs in the new research project »CoCoMe«.

[MORE INFO](#)



Ministry of Trade,
Industry and Energy

Acknowledgement



Department Head

Dr. Armin Wedel

QD Team

Dr. André Geßner - **Leader**
Benjamin Heyne
Hyung Seok Choi
Kristin Arlt] - **Synthesis**
Dr. Yohan Kim - **Device**

Printing Team (OLED & OPV)

Dr. Christine Boeffel - **Leader**
Dr. Manuel Gensler - **ES-JET**
Bert Fischer - **Ink-jet**
Franziska Ebert
Stefan Kröpke
Stefanie Kreißl] - **Applications**

SPONSORED BY THE



Federal Ministry
of Education
and Research



Project
funded by the
EUROPEAN UNION



Thank you for your attention!

Want to know more?

Dr. Armin Wedel

Fraunhofer Institute for Applied Polymer Research (IAP)
Geiselbergstraße 69
D-14476 Potsdam-Golm

armin.wedel@iap.fraunhofer.de

+49 (0) 331 568 - 1915

